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*NANONEX RECEIVES FIRST ORDER FOR THE ULTRA-100, A NEW  
INTEGRATED UV-OZONE CLEANER-MOLECULAR VAPOR COATER UNIT  
FROM SANDIA NATIONAL LABORATORIES IN LIVERMORE, CALIFORNIA*

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**Princeton, NJ, June 18, 2006:** Nanonex Corporation, the leader in nanoimprint solution and applications with the longest history, announces today the first order received from Sandia National Laboratories in Livermore, California, for the newly introduced *Ultra-100*, a desktop-design integrated UV-Ozone cleaner and molecular vapor coater unit.

The *Ultra-100* is designed to be used for nanoimprint mask treatment for release, surface adhesion promotion, MEMS NEMS antistiction coating, micro and nano fluidic channel surface treatment, all-purpose UV-Ozone cleaning, resist stripping, as well as UV curing in vacuum or gas environment.

Sandia National Laboratories will use the *Ultra-100*, in part, to support their existing NX-2000 nanoimprint lithography system supplied and installed by Nanonex in 2005.

John Pong, Nanonex's Sales Director said Nanonex is delighted that Sandia has continued to select Nanonex to be their advanced nanoimprint lithography solution provider. The *Ultra-100* (and the Nanonex NX2000 imprinter) will support the very important nanotechnology research activities at the national laboratories.

Nanonex also has supplied nanoimprint materials (resists and molds) to customers in USA, Canada, UK, France, Germany, Japan, Taiwan, Korea and Singapore.

**About Nanonex Corp.**

Nanonex, a pioneer and a leader in nanoimprint, provides a complete line of nanoimprint lithography (NIL) technology solutions including tools, masks, and processes. Nanonex NIL solutions offer sub 10 nm feature resolution, 3D patterning, large area uniformity, accurate overlay alignment, high-throughput, and low cost. Nanonex NIL solutions include all forms of nanoimprinting, such as thermal plastic, uv-curable, thermal curable, and direct imprinting (embossing). Nanonex NIL solutions can meet the needs of a broad spectrum of markets, such as optical devices, displays, data storage, biotech, IC, chemical synthesis, and advanced materials. Visit [www.nanonex.com](http://www.nanonex.com) for additional information.